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Oxygen self-diffusion mechanisms in monoclinic ZrO_{2} revealed and quantified by density functional theory, random walk analysis, and kinetic Monte Carlo calculations Jing Yang, Mostafa Youssef, and Bilge Yildiz Phys. Rev. B **97**, 024114 – Published 29 January 2018 DOI: 10.1103/PhysRevB.97.024114 Oxygen self-diffusion mechanisms in monoclinic ZrO₂ revealed and quantified by density functional theory, random walk and kinetic Monte Carlo calculations

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Abstract

In this work, we quantify oxygen self-diffusion in monoclinic-phase zirconium oxide as a function of temperature and oxygen partial pressure. Migration barrier of each type of oxygen defect was obtained by first-principles calculations. Random-walk theory was used to quantify the diffusivities of oxygen interstitials by using the calculated migration barriers. Kinetic Monte Carlo simulations was used to calculate diffusivities of oxygen vacancies by distinguishing the three-fold and four-fold coordinated lattice oxygen. By combining the equilibrium defect concentrations obtained in our previous work together with the herein calculated diffusivity of each defect species, we present the resulting oxygen self-diffusion coefficients, and the corresponding atomistically resolved transport mechanisms. The predicted effective migration barriers and diffusion pre-factors are in reasonable agreement with the experimentally reported values. This work provides insights into oxygen diffusion engineering in ZrO₂ related devices and parameterization for continuum transport modeling.

I. Introduction

Oxygen self-diffusion in zirconium oxide has been a topic of interest for long[1-4] in studying the oxidation kinetics of zirconium alloys, which are used as cladding of nuclear fuel in light water cooled nuclear reactors.[5] Zirconium oxide is also widely used in heterogeneous catalysis[6, 7], and more recently examined for high-*k* dielectrics in metal-oxide-semiconductor field-effect transistor (MOSFET) devices[8, 9] as well as resistive switching devices[10, 11]. In all of these technologically important applications, understanding the defect chemistry and transport properties is key to better material design, device engineering and performance modeling. In particular, such knowledge could guide design by means like aliovalent doping and controlling operating environmental conditions. Experimental [12-14] and computational [15-20] studies have been carried out to atomistically resolve the structure, valence states and defect chemistry in ZrO₂. Zirconium-oxygen system phase stability has been examined by first-principles studies, and a range of sub-oxide structures with oxygen dissolved into the metal phase have been identified.[20] To date, many aspects of ZrO₂ remain unexamined atomistically in the multi-dimensional space of temperature, oxygen partial pressure, extrinsic doping, strain and microstructure. In our previous work, we have predicted oxygen self-diffusion kinetics in tetragonal-ZrO₂ (t-ZrO₂) by combining first-principle calculations with random-walk theory[21], resulting in good agreement with experimental measurements. Monoclinic-ZrO₂ (m-ZrO₂) is the stable phase below 1440 K[22] and is also relevant in the applications mentioned above. In m-ZrO₂, the oxygen sub-lattice is distorted compared to the tetragonal phase, leading to two inequivalent sites for oxygen in the unit cell: one bonds with four zirconium atoms (O4) and one bonds with three zirconium atoms (O3). This inequivalence of oxygen sites makes random-walk model inapplicable. There exists first-principle studies of oxygen defects migration barriers in HfO₂, which bears the same structure as m-ZrO₂.[23] However, no comprehensive work predicting overall oxygen diffusion coefficients has been performed for oxides of this structure.

In this study, we present a systematic examination of oxygen transport properties in bulk, near-stoichiometric monoclinic- ZrO_2 under different thermodynamic conditions. In previous work, by combining first-principles based point defect calculations with statistical thermodynamics, we were able to predict equilibrium defect concentrations at various temperatures and oxygen partial pressures both in tetragonal[24] and monoclinic $ZrO_2[16]$. Here we calculated the migration barriers of different oxygen defect types and migration paths by first principles calculations. The results show that migration barriers corresponding to different oxygen vacancy migration paths categorized by O4 and O3 sites could differ by more than 1 eV. In order to distinguish this inequivalence of lattice oxygen sites, we quantified the oxygen vacancy diffusivity with kinetic Monte-Carlo (kMC) simulations. On the other hand, random walk theory was sufficient to obtain the oxygen interstitial diffusivities. We arrive at the total oxygen self-diffusion coefficients by combining the defect equilibria and diffusivity for each of these oxygen defects over a wide range of temperature and oxygen partial pressure.

The predicted diffusion coefficient profiles show a valley shape as a function of oxygen pressure at different temperatures. Oxygen interstitial dominates in the high oxygen partial pressure regime and oxygen vacancy in the low oxygen partial pressure regime, leading to a diffusion minimum at intermediate oxygen partial pressures. Our predicted values are in good agreement with experimentally measured diffusion coefficients under relevant thermodynamic conditions. Finally, we discuss the implications of this study on engineering oxygen transport in zirconium oxide.

II. Methods

The climbing image nudged elastic band (CI-NEB) method[25] was used to calculate migration barriers using three to five intermediate images as implemented in Transition State Tools (VTST)[25]. Energies of each image were calculated by density functional theory (DFT) with Vienna Ab initio Simulation Package (VASP)[26-29] with $2 \times 2 \times 2$ supercell and $2 \times 2 \times 2$ *k*-point gird. The generalized gradient approximation

(GGA) with Perdew-Burke-Ernzerhof (PBE) functional[30, 31] is used. $4s^24p^64d^25s^2$ electrons for zirconium and $2s^22p^4$ for oxygen are treated as valence electrons. The plane-wave cutoff energy was set to 450 eV. Details of calculating the defect formation energies and equilibrium defect concentrations can be found in Ref. [24], [16] and [32].

For oxygen interstitials, DFT calculations were performed with different initial guesses for the interstitial sites. Oxygen vacancies can take either O4 or O3 sites. On the other hand, the interstitial oxygen always occupies the same type of site in the relaxed, low-energy configurations. This finding validates the applicability of the random-walk theory for oxygen interstitials, as we reported earlier for oxygen diffusion in t-ZrO₂[21]. In principle, random-walk theory produces the same outcome as kinetic Monte Carlo simulations for oxygen interstitials, given that there is no inequivalent sites for them in m-ZrO₂. Therefore, the diffusivity for each oxygen interstitial species was calculated by the random-walk model[33] with

$$D_{O_i}^{q} = \sum_{k} v d_k^2 \exp(-\frac{E_k}{k_B T}) \quad , \tag{1}$$

where attempt frequency V is taken as 5 THz. q represents the different charged states of oxygen interstitials (0, -1 and -2). E_k and d_k are the migration barrier and hopping distance for the corresponding migration path. k_B is the Boltzmann constant and T is temperature. Kröger-Vink notation for defects is used throughout this paper.

The calculated migration barriers for oxygen vacancies were fed into an on-lattice kinetic Monte Carlo model [34] to account for the three-fold and four-fold

coordinated oxygen site network. Simulations were performed at each temperature for 10^{6} kMC steps. The simulation cell has one defect in ZrO₂ lattice with periodic boundary condition, starting from a random initial configuration. The diffusivity is calculated from the mean square displacement with Einstein's theory of Brownian motion [35],

$$\left\langle \mathbf{r}(t)^{2}\right\rangle = 6D_{V_{O}}^{q}t.$$
 (2)

Here $\mathbf{r}(t)$ is the position of the defect referenced to the initial site at time *t*, and $D_{t_o}^q$ is the calculated diffusivity for the specific defect species V_o^q at that temperature. The calculation of $D_{t_o}^q$ from the kMC trajectory involves the following. For each defect species, one trajectory of N steps is obtained from kMC run. This single trajectory is broken into N/n trajectories with n steps. For each n-step trajectory, an associated diffusivity D_n is calculated by $D_n = \Delta r_n^2 / 6t_n$, where Δr_n^2 represents the total mean squared displacement of this trajectory and t_n represents the total time. Due to the nature of kMC, t_n is different for each n-step trajectory. The final diffusivity is calculated by averaging D_n from the (N/n) trajectories. In this work, N = 10^6 and n = 5 × 10^3 was used. Convergence of the simulations with these parameters are shown in the supplemental material [37]. Defect-defect interactions are ignored in all calculations under the assumption of dilute limit which is reasonable for undoped monoclinic ZrO₂ which does not exhibit significant deviation from stoichiometry [16, 36].

By combining the contribution to diffusion by oxygen vacancies from kMC calculations and by oxygen interstitials from random-walk theory, we obtain the total

oxygen self-diffusion coefficient at different partial pressures and temperatures

$$D_{tot} = \sum_{q} [V_{O}^{q}] D_{V_{O}}^{q} + \sum_{q} [O_{i}^{q}] D_{O_{i}}^{q} \quad .$$
(3)

Here [d] is the concentration of respective defect. D_{tot} defined here is the isotropic diffusion coefficient of oxygen averaged over all crystallographic directions. This value is then compared with experimental values in the results section.

III. Results and discussion

The considered pathways of oxygen vacancy migration are shown schematically in Fig. 1. Two types of oxygen sites exist in monoclinic ZrO_2 , one type bonded with four zirconium ions (O4) and the other with three (O3). The migration paths are further categorized by the number of zirconium ions that simultaneously share bonds with the two oxygen sites between which the migration takes place. Details of each migration path and the corresponding migration barriers are summarized in Table 1 and the energy profiles in Figure 2. For each migration path, the barrier for oxygen vacancies with 0, +1 and +2 charges are calculated.



Figure 1. Migration paths for oxygen vacancies in m-ZrO₂. Large, green spheres represent Zr ions. Small red and grey spheres represent three-fold-coordinated and four-fold-coordinated oxygen ions, respectively. This figure is generated with visualization software VESTA.[38]

Table 1. The calculated migration paths and migration barriers (in units of eV) of oxygen vacancies in m-ZrO₂. The indices of each migration path are labeled in Fig. Figure 1. The paths are categorized by O4 and O3 oxygen sites, and how many Zr ions the two O sites share bond with. For paths between O4 and O3 sites, forward and backward barriers are different due to asymmetry of the initial and final configuration. For O4-O4 and O3-O3 paths, forward and backward barriers are equal. For O4-O4 paths, migration on ab plane and c direction are further distinguished.

Path	From-To	Shared Zr ion		V_o^{\times}	V_o^{\bullet}	$V_{O}^{\bullet \bullet}$
1	04 03	2	forward	1.94	0.91	0.06
	04 - 03		backward	1.84	1.28	0.78
2	04 - 03	1	forward	2.23	1.64	1.01
			backward	2.12	2.00	1.80
3	O4 - O4, c	2		2.48	1.54	0.86
4	O4 - O4, ab	2		2.03	1.20	0.33
5	O3 - O3	2		2.20	1.58	0.77
6	03 - 03	1		1.32	1.11	0.73



Figure 2. Energy profiles for oxygen migration paths labeled in Figure 1. Red dots are images calculated by the CI-NEB method. Fitted spline curves are produced with the VTST tools.[25]

Based on the calculated migration barrier, it is clear that for each migration path, the higher-charge-state oxygen vacancies have lower migration barriers. This can be rationalized by the fact that the diffusive jump of V_o^{\times} involves the transport of the two electrons associated with the vacant site in a direction opposing the jump of the oxide ion. This opposition is accompanied with Coulombic repulsion and elevation of the activation barrier. In the case of V_o^{\bullet} , there is only one electron opposing the migrating oxide ion and finally in $V_o^{\bullet\bullet}$ there are no electrons to oppose the oxide ion. Similar trend has also been observed in tetragonal ZrO₂[21] and other oxides[39]. It is also notable that the forward migration barrier for O4-O3 sharing bonds with Zr ions is as low as 0.06 eV, which seemingly indicates very fast oxygen diffusion. However, it is shown from kMC simulations that, although oxygen hopping between these two types of sites is frequent, oxygen atoms need to go through other high-barrier migration paths in order to complete long-range diffusion.

For oxygen interstitials, octahedral interstitial sites were found to be the low-energy sites.[16] DFT calculations show that all octahedral oxygen interstitials are energetically equivalent in the ZrO₂ unit cell. Migration barriers for direct exchange mechanism were found to be too high (> 5 eV) and therefore only interstitialcy migration hops were considered.[40] The calculated migration barriers are 0.672 eV, 0.365 eV, and 0.530 eV respectively for O_i^{\times} , O_i' , and O_i'' . These results indicate oxygen interstitials have higher mobility compared to oxygen vacancies, consistent with previous experimental observation[1].

Equilibrium defect concentrations as a function of P_{O_2} at 600 K and 1200 K are reproduced in Fig. 3 (a)(b). Details of how these profiles are constructed can be found in Ref. [16]. At 600 K, the dominant oxygen-related defect is oxygen interstitial over the entire P_{O_2} range, with the dominant charge state changing from -2 to 0 at 1 atm. At 1200 K, the dominant oxygen defect transitions from oxygen vacancy with different charge states for $P_{O_2} < 10^{-12}$ atm to doubly-charged oxygen interstitial O_i'' at higher, more oxidizing P_{O_2} .



Figure 3. Equilibrium concentrations of electronic and ionic defects, [d] at (a) 600 K and (b) 1200 K, as a function of oxygen partial pressure. Oxygen self-diffusivity, D, calculated for each oxygen defect species and total diffusion coefficient, D_{tot} , with varying oxygen partial pressure at (c) 600 K and (d) 1200 K.

The total oxygen self-diffusivity profiles as well as contributions of individual oxygen defect species at the two temperatures display different features (Figure 3(c) and 3(d)), following the defect transitions noted above. In the low-temperature case, P_{O_2} dependence can be categorized into two regimes. In the low P_{O_2} regime (< 10⁻²⁰ atm), the dominant charged defects are holes compensated by electrons. This results in a 1/2 slope of for the concentration of the dominant oxygen defect O_i'' , and

consequently the same slope for $\log_{10}D_{tot}$ profile. In the high P_{O_2} regime (>10⁻¹⁰ atm), holes are charge-balanced by zirconium vacancies $V_{Zr}^{\prime\prime\prime\prime\prime}$. Here the defect reaction is $\frac{1}{2}O_2(g) \rightarrow O_0^{\times} + \frac{1}{2}V_{Zr}^{\prime\prime\prime\prime\prime} + 2h^{\bullet}$, leading to $[h^{\bullet}] = \frac{1}{4}[V_{Zr}^{\prime\prime\prime\prime\prime}] \propto P_{O_2}^{-1/5}$. The concentration of $O_i^{\prime\prime}$ is related to $[h^{\bullet}]$ via defect reaction $\frac{1}{2}O_2(g) \rightarrow O_i^{\prime\prime} + 2h^{\bullet}$ and thus exhibits the 1/10 slope as shown in the $\log_{10}D_{tot}$ curve.

At high-temperature, the intermediate P_{O_2} regime $(10^{-15} - 10^{-10} \text{ atm})$ has the same electron-hole compensation mechanism and the same dominant oxygen defect O_i'' as discussed above, and thus, $\log_{10}D_{\text{tot}}$ exhibits 1/2 slope. However, in low P_{O_2} regime, the two dominating types of charged defect are electrons and positively-charged oxygen vacancies. A -1/6 $\log_{10}D_{\text{tot}}$ slope is predicted by the law of mass action under the approximate charge neutrality $n_c \approx 2[V_0^{\bullet}]$, but a small discrepancy from this prediction was present in the calculated curve. This is because of the fact that V_0^{\bullet} also contributes non-negligibly to the charge neutrality condition. At very low P_{O_2} , V_0^{\bullet} and V_0^{\times} predominate over $V_0^{\bullet\bullet}$ in concentration, but the diffusivity is still contributed mainly by $V_0^{\bullet\bullet}$ due to its lower migration barrier. In the high P_{O_2} regime, $p_v \approx 2[O_i'']$. $\frac{1}{2}O_2(g) \rightarrow O_i'' + 2h^{\bullet}$ is the dominant defect reaction and a 1/6 slope is shown as predicted by law of mass action.



Figure 4. Calculated total oxygen self-diffusion coefficient plotted as a function of oxygen partial pressure and temperature. Dotted lines in (b) show experimentally measured values from references [1] (0.92 atm), [2] (0.39 atm), and [3] (0.13 and 0.03 atm).

To examine the gradual transition from the low-temperature behavior to the high-temperature behavior, we plot the P_{O_2} dependence of total self-diffusion coefficient at different temperatures in Fig. 4(a). There is clear appearance of a diffusion coefficient minima, or valley, as marked by the dashed line. This marks the transition between the $V_0^{\bullet\bullet}$ -dominated regime to the $O_i^{\bullet\bullet}$ -dominated regime. At low temperatures (<700 K), the entire P_{O_2} range is dominated by oxygen interstitials. At higher temperatures, there is a transition between $V_0^{\bullet\bullet}$ -dominated regime at low P_{O_2} and $O_i^{\bullet\bullet}$ -dominated regime at high P_{O_2} . The oxygen partial pressure at which this transition happens, increases with increasing temperature.

To compare with experiments, the high temperature data are replotted in Fig. 4(b) as isobaric diffusion coefficient curves as a function of 1/T. At high P_{O_2} (>10⁻⁵ atm), the isobaric curves are perfectly Arrhenius. This is because the entire profile is sampled in regimes where oxygen interstitials are compensated by holes. At intermediate P_{O_2} (10⁻¹⁰ - 10⁻⁵ atm), non-Arrhenius behavior starts to appear, where the compensation mechanism transitions to electrons compensated by holes. At even lower P_{O_2} , the Arrhenius behavior is restored again because now the entire region is within the vacancy-dominated regime.

Symbols in Fig. 4(b) represent experimentally measured values at different oxygen partial pressures as noted in the legend. [1-3] It is clear from Fig. 4(b) that experimental measurements have considerable disagreement between each other. In particular, the trend of D_{tot} varying with oxygen partial pressure is not consistent when comparing values from different studies. Here we discuss a few factors that possibly lead to this discrepancy. First, all experimental studies listed here were not conducted on single-crystal ZrO₂. Ref. [1] and [2] measured conductivity by ¹⁸O diffusion experiment on ZrO₂ spheres, and Ref. [3] by measuring the oxidation rate of non-stoichiometric ZrO₂ powder to stoichiometric ZrO₂. It is hard to eliminate the contribution of voids, grain boundaries or other types of extended defects. Second, all diffusion models used to fit experimental profiles and obtain D_{tot} assume that the rate-limiting step in the oxygen exchange/oxidation process is oxygen diffusion. This simplified assumption may lead to errors in the fitted result. This point is partially

verified by Ref. [1], where the authors found that diffusivities obtained at equivalent oxygen partial pressure by CO/CO_2 mixture and O_2 gas are not consistent, indicating that surface exchange kinetics also influence the result. Third, none of these studies considers the contribution to oxygen diffusion under electric field in intrinsically formed space charge layer at oxide surface. Our study shows that the major contribution to diffusion coefficient comes from charged defects and the space charge effect should be taken into consideration.[32]

Last, it is worth mentioning that experimental specimens must contain aliovalent cation impurities. For example, Al^{3+} and Nb^{5+} are two common impurity species, one is an acceptor and the other is a donor. These aliovalent cations could compensate with each other and make the oxide behave closer to intrinsic. However, even a small amount of n-type or p-type doping could change the dependence of defect chemistry to oxygen partial pressure. In particular, the compensating mechanism transition pressure could change due to the impurity dopants. In other words, the same defect chemistry could be achieved at different P_{O_2} with different impurity contents. This could in part explain the inconsistency of P_{O_2} dependence between prior experimental studies. The trend in diffusivity change from 0.03 to 0.13 atm in Ref. [3] is more reliable considering the measurements were performed on samples with the same impurity level. In Ref. [3] we see that D_{tot} increases with oxygen partial pressure, which hints to an oxygen interstitial dominated mechanism and is in agreement with our prediction.

To quantitatively compare with experimentally measured values, we calculate the

effective activation energies Q and effective pre-factors D^* by fitting the total self-diffusivity D_{tot} to $D_{tot} = D^* \exp(-Q/k_B T)$. The outcome values are plotted in Fig. 5 and summarized in Table 2. It is not a coincidence that both the activation energy and the diffusion pre-factor curves display a valley at intermediate oxygen partial pressure. This valley again corresponds to the same transition from $V_o^{\bullet \bullet}$ -dominated regime at low P_{O_2} to O''_i -dominated regime at high P_{O_2} . The effective activation barrier predicted at $P_{O_2} = 1$ atm is 2.04 eV. This is in reasonable agreement with experimentally measured values (1.96 eV[1], 2.43 eV[2] and 2.46 eV[3] respectively). This consistency indicates that all the values we are comparing with from experiments should be in the same O''_{i} -dominated regime as we predicted. This is because the formation energy of $V_0^{\bullet\bullet}$ alone exceeds 3.5 eV in this P_{O_2} range and even higher activation barrier should be expected if $V_0^{\bullet\bullet}$ were the dominant species. When it comes to diffusion pre-factors, the difference between this work and experimental values, and the difference among the reported experimental values, is more pronounced. D^* predicted in this study is 6.50×10^{-3} cm²/s at $P_{O_2} = 1$ atm and 4.76×10^{-3} cm²/s at $P_{O_2} = 0.1$ atm. The calculated value in Ref [1], [2] and [3] are 2.34×10^{-2} cm²/s at 0.92 atm, 9.73×10^{-3} cm²/s at 0.39 atm, 1.82 cm²/s at 0.13 atm and 9.00×10^{-2} cm²/s at 0.03 atm. However, we can also see from Fig. 5(b) that D^* changes over orders of magnitude with varying oxygen partial pressures. This observation is consistent with the different impurity argument we discussed above. Acceptor-type impurity could increase the concentration of O_i'' and hence create the discrepancies among D^* .



Figure 5. (a) Activation energies and (b) diffusion pre-factors at different oxygen partial pressures fitted to $D_{tot} = D^* \exp(-Q/k_B T)$ by using the simulated data in the high temperature regimes in Fig. 4(b).

	This work	This work	This work	Ref. 1	Ref. 2	Ref. 3	Ref. 3
P_{O_2}	1	0.1	0.01	0.92	0.39	0.13	0.03
(atm)							
Q(eV)	2.04	2.05	2.05	1.96	2.43	2.46	2.46
D^*_{2}	6.50	4.76	3.16	2.34	9.73	1.82	9.00
(cm²/s)	×10 ⁻³	×10 ⁻³	×10 ⁻³	×10 ⁻²	×10 ⁻³		×10 ⁻²

Table 2. Activation energies and diffusion pre-factors comparison between this work and experimental measurements.

Lastly, we comment on the implication of these findings on the oxidation rate of zirconium metal. Oxygen diffusion through the oxide passive film is known as one of the rate limiting steps in the oxidation process.[41] To design corrosion-resistant zirconium alloys, lower oxygen diffusivity is desirable. Looking at the isothermal curves in Fig. 4 (a), the lowest oxygen diffusion coefficient is always achieved in

intermediate pressure range where the dominating species are electrons and holes. Going to the high/low end of oxygen partial pressure, oxygen interstitial/oxygen vacancy becomes the dominant defect species that compensate with holes/electrons, and thus increases total oxygen conductivity. This leads to the conclusion that, to engineer oxygen transport through the oxide film, it is desirable to suppress the dominant oxygen defect. Doping is one of the possible means to achieve this goal. In the high P_{O_2} region, +3 dopant could compensate with hole, reducing oxygen interstitial concentration and thus suppressing oxygen transport. +5 dopant has similar effect in the low P_{O_2} region in compensating with electrons and reducing oxygen vacancy. This finding provides guiding rules for different alloying elements that can dissolve into the growing oxide and change the oxygen defect equilibria in the relevant temperature and oxygen partial pressure space.

In light of our findings, we offer a few possible improvements on the modeling method used in this work. First, we ignored defect-defect interactions throughout this study. If we look at Fig. 3(b), the calculated defect concentrations are generally below 10 ppm, which shows that this approximation is reasonable within the thermodynamic regime considered here. However, if high concentration of extrinsic doping or higher temperature and lower oxygen pressure regime is of interest, it will be important to include defect-defect interactions. Second, extended defects in the oxide structure can significantly change its transport properties, for example, as we have demonstrated recently for secondary phase particles embedded in ZrO₂ matrix.[32] The effects of surface, grain boundaries and interfaces on oxygen diffusion are also worth exploring,

and this is necessary for constructing accurate higher-level transport models as well as informing microstructure engineering for oxide materials.

IV. Conclusion

In this study, we modeled oxygen self-diffusion in monoclinic-ZrO₂ by combining density functional theory calculations, random walk theory, and kinetic Monte Carlo simulations. Oxygen diffusion coefficient shows a clear transition between an oxygen vacancy dominated transport regime at low oxygen partial pressure to an oxygen interstitial dominated regime at high oxygen partial pressures. The results demonstrate a diffusivity minima, a valley at the transition point. The effective migration barriers and diffusion pre-factors are in reasonable agreement with those found from experimental studies. This study provides atomistic understanding of oxygen diffusion mechanism in monoclinic ZrO₂, and the findings can guide the design of zirconium oxide for different applications where oxygen transport properties at different functional conditions are of interest.

ACKNOWLEDGMENTS

This work is supported by the Consortium for Advanced Simulation of Light Water Reactors (CASL), an Energy Innovation Hub for Modeling and Simulation of Nuclear Reactors under U.S. Department of Energy Contract No. DE-AC05-00OR22725. We acknowledge the Extreme Science and Engineering Discovery Environment (XSEDE) program for calculations performed under allocation No. TG-DMR120025. [1] F. J. Keneshea and D. L. Douglass, Oxidation of Metals 3, 1 (1971).

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